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Ning-Hua Zhu
Jinmin Li
Farzin Amzajerdian
Hiroyuki Suzuki
Editors

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Contents

- vii *Symposium Committees*
- ix *Conference Committee*
- xi *Fibre optic systems for gas detection principles, progress, and prospects (Plenary Paper) [7853-150]*
B. Culshaw, Univ. of Strathclyde (United Kingdom)

SESSION 1 NOVEL SEMICONDUCTOR LASERS

- 7844 02 **Novel semiconductor lasers and integrated photonic devices (Invited Paper) [7844-01]**
J.-J. He, J. Jin, D. Liu, L. Jin, M. Lou, T. Yu, L. Wang, Zhejiang Univ. (China)
- 7844 04 **High brightness InAs/GaAs quantum dot tapered laser at 1.3 μm with high temperature stability [7844-03]**
Y.-L. Cao, P. Xu, H.-M. Ji, T. Yang, L.-H. Chen, Institute of Semiconductors (China)
- 7844 05 **Beam-shaping of laser diode stack for uniform illumination by cylindrical micro-lenses [7844-04]**
W. ShangGuan, H. Yan, Y. Jiang, X. Zhang, C. Yang, Zhejiang Univ. (China)
- 7844 09 **Experimental demonstration of a widely tunable two-section DFB laser [7844-08]**
Y. Wang, M. Li, J.-J. He, Zhejiang Univ. (China)

SESSION 2 SEMICONDUCTOR LASER APPLICATIONS

- 7844 0D **Optical fiber sensors for landslide monitoring (Invited Paper) [7844-12]**
Y. Liu, Z. Dai, X. Zhang, Z. Peng, J. Li, Z. Ou, Y. Liu, Univ. of Electronic Science and Technology of China (China)
- 7844 0E **Suppression of time delay signatures of chaotic output in mutually delay-coupled semiconductor lasers [7844-13]**
J.-G. Wu, Southwest Univ. (China); Z.-M. Wu, Southwest Univ. (China) and Southeast Univ. (China); J.-T. Shen, L. Ding, N.-Y. Li, Southwest Univ. (China); G.-Q. Xia, Southwest Univ. (China) and Southeast Univ. (China)
- 7844 0H **Power equalization using nonlinear polarization rotation in a single semiconductor optical amplifier (Invited Paper) [7844-16]**
S. J. Zhang, Y. L. Zhang, K. Zhang, S. Liu, Y. Z. Liu, Y. Liu, Univ. of Electronic Science and Technology of China (China)
- 7844 0I **A novel optical heterodyne approach for measuring frequency responses of photodetectors [7844-17]**
Q. Yan, Y. Huang, X. Duan, D. He, H. Huang, X. Zhang, Q. Wang, X. Ren, Beijing Univ. of Posts and Telecommunications (China)

SESSION 3 SIMULATION, CHARACTERISTICS, AND PACKAGING

- 7844 0K **Phase estimation in coherent communication systems with semiconductor laser noises (Invited Paper)** [7844-19]
C. Yu, National Univ. of Singapore (Singapore) and A*STAR Institute for Infocomm Research (Singapore); P. Y. Kam, S. Zhang, A*STAR Institute for Infocomm Research (Singapore); J. Chen, Nanjing Univ. of Posts and Telecommunications (China)
- 7844 0L **Theoretical analysis of emission characteristics of second-order distributed feedback semiconductor lasers** [7844-20]
L. Qin, Changchun Institute of Optics, Fine Mechanics and Physics (China); S. Ye, Y. Hu, N. Zhang, Changchun Institute of Optics, Fine Mechanics and Physics (China) and Graduate Univ. of Chinese Academy of Sciences (China); Y. Ning, Y. Liu, L. Wang, Changchun Institute of Optics, Fine Mechanics and Physics (China)
- 7844 0M **Intracavity second harmonic generation characteristics of semiconductor disk laser** [7844-21]
Z. Li, Y. Song, P. Zhang, X. Zhang, Beijing Univ. of Technology (China)
- 7844 0N **Optical bistability in InP/InAlGaAs multi-quantum-well semiconductor ring lasers** [7844-22]
Y. Chen, L. Mao, W. Guo, S. Zhang, S. Xie, J. Yu, X. Yu, Tianjin Univ. (China); X. Li, L. Qi, China Electronics Technology Group Corp. (China); X. Gu, Tianjin Polytechnic Univ. (China)
- 7844 0O **Electromagnetic optimization of high-speed TO laser modules (Invited Paper)** [7844-23]
W. Han, P. O'Brien, M. Rensing, H. Yang, Tyndall National Institute (Ireland); F. H. Peters, Tyndall National Institute (Ireland) and Univ. College Cork (Ireland)
- 7844 0P **High-speed analog DFB laser module operated in direct modulation for Ku-band (Invited Paper)** [7844-24]
Y. Liu, J. W. Man, W. Han, X. Wang, H. Q. Yuan, H. L. Zhu, L. Xie, N. H. Zhu, Institute of Semiconductors (China)
- 7844 0Q **Experimental observations of bistable characteristics of an optically injected semiconductor laser biased nearby the threshold current** [7844-25]
X.-D. Lin, Southwest Univ. (China); Z.-M. Wu, Southwest Univ. (China) and Southeast Univ. (China); L. Wang, X.-X. Ping, Southwest Univ. (China); G.-Q. Xia, Southwest Univ. (China) and Southeast Univ. (China)
- 7844 0R **Influence of asymmetrical bias currents on chaos synchronization performance of mutually coupled semiconductor lasers** [7844-26]
T. Deng, G.-Q. Xia, Y. He, Y.-Y. Liu, Southwest Univ. (China); Z.-M. Wu, Southwest Univ. (China) and Southeast Univ. (China)
- 7844 0S **Analysis of strain energy in nanowire heterostructures with component gradient buffer section** [7844-27]
Y. Liu, X. Ye, H. Huang, J. Guo, X. Ren, Y. Huang, Beijing Univ. of Posts and Telecommunications (China)
- 7844 0T **Experimental study of laser dicing sapphire substrate by green DPSS laser** [7844-28]
X. Xie, F. Huang, X. Wei, W. Hu, Q. Ren, Guangdong Univ. of Technology (China)

POSTER SESSION

- 7844 0W **A common aperture active imaging system** [7844-31]
N. Zhang, Y. Tang, L. Zhang, G. Huang, Beijing Institute of Technology (China)
- 7844 0Y **Self-mixing interference effect of VCSEL and the application on microdisplacement measurement** [7844-33]
H. Hao, M. Wang, D. Guo, W. Xia, Nanjing Normal Univ. (China)
- 7844 0Z **Distributed Bragg reflector mirror with a double-wavelength reflection: design and calculation** [7844-34]
C. Yan, L. Xu, Y. Feng, Y. Hao, Y. Deng, Y. Zhao, J. Zhong, C. Tian, X. Jia, Changchun Univ. of Science and Technology (China)
- 7844 10 **A simple wavelength-locking scheme of a tunable three-electrode distributed Bragg reflector laser for multiple ITU channel application in C band** [7844-35]
N. Ye, Y. Liu, L.-J. Zhao, Institute of Semiconductors (China)
- 7844 11 **Optical influence of different standard illuminants on green nephrite's color From Manasi** [7844-36]
H. Du, Y. Guo, China Univ. of Geosciences (China)
- 7844 12 **The contribution of Cu^{2+} , Fe^{2+} , F^{3+} to bluish green color of HuBei turquoise** [7844-37]
Y. Guo, L. Jin, China Univ. of Geosciences (China); H. Sun, China Building Material Test & Certification Ctr. (China)
- 7844 13 **Lifetime estimation of high power lasers** [7844-38]
G. Lu, Y. Huang, Y. En, Science and Technology on Reliability Physics and Application of Electronic Component Lab. (China)
- 7844 16 **An InP-based wide gain spectrum asymmetric quantum wells for large scale optoelectronic monolithic integration** [7844-41]
H. Xie, Z. Lu, P. Shen, C. Ding, L. Chen, W. Zhang, Beijing Univ. of Technology (China)
- 7844 17 **A special sampling technology for sampled grating laser** [7844-42]
Y. Zhou, Nanjing Univ. (China) and Changzhou Institute of Technology (China); Y. Shi, S. Li, X. Chen, Nanjing Univ. (China)
- 7844 18 **Multiple phase shifts DFB semiconductor laser based on reconstruction equivalent chirp technology** [7844-43]
Y. Shi, S. Li, L. Lu, X. Chen, Nanjing Univ. (China)
- 7844 19 **Hydrogen and argon plasma passivation technology in GaAs/AlGaAs LD cavity surfaces** [7844-44]
C. Liu, C. Wang, Y. Yao, Jilin Normal Univ. (China)
- 7844 1A **Collimated the laser diode beam by the focus lens** [7844-45]
Q. Xu, J. Li, W. Zhang, Xidian Univ. (China)

- 7844 1B **Optimal design and experimental realization of DBR-metal microcavity organic lasers** [7844-46]
X. Zhao, Xi'an Jiaotong Univ. (China) and Xi'an Research Institute of Hi-Tech (China); Z. Wu, S. Liang, X. Hou, Xi'an Jiaotong Univ. (China)
- 7844 1C **Demonstrations of beam quality of semiconductor lasers** [7844-47]
C. Cao, X. Zeng, Y. An, Xidian Univ. (China)
- 7844 1E **Optimization of low threshold currents in proton implanted vertical cavity surface emitting lasers** [7844-49]
H.-D. Zhao, M. Sun, Q. Liu, W. Wang, H.-L. Liu, W.-C. Li, Hebei Univ. of Technology (China)
- 7844 1F **Frequency stabilized system of the reference laser diode for space-borne Fourier transform spectrometer** [7844-50]
X. Jin, Z. Dai, R. Chen, D. Li, X. Sun, Shanghai Institute of Technical Physics (China)
- 7844 1G **The theoretical research of the carriers distribution in the semiconductor quantum dot** [7844-51]
C. Zhao, M. Zhao, Y. Wang, Beijing Institute of Petrochemical Technology (China); Y. Cao, Beijing Institute of Petrochemical Technology (China) and Beijing Univ. of Chemical Technology (China); A. J. Lv, X. L. Liu, G. J. Xing, Beijing Institute of Petrochemical Technology (China)
- 7844 1H **High-power, mode-locking, external-cavity feedback diode-pumped laser based on SHG in PPKTP** [7844-52]
W. Li, Hebei Univ. of Technology (China) and Qinhuangdao College of Profession Technology (China); Z. Liu, Yanshan Univ. (China); H. Zhao, Hebei Univ. of Technology (China); Z. Li, Yanshan Univ. (China)

Author Index

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- 1 Novel Semiconductor Lasers
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- 2 Semiconductor Laser Applications
Changyuan Yu, National University of Singapore (Singapore)
Lianshan Yan, Southwest Jiaotong University (China)
- 3 Simulation, Characteristics, and Packaging
Kun Xu, Beijing University of Posts and Telecommunications (China)
Yongzhi Liu, University of Electronic Science and Technology of China (China)